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Formation of Nanopatterned Polymer Blends in Photovoltaic Devices

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ABSTRACT In this paper, we demonstrate a double nanoimprinting process that allows the formation of nanostructured polymer heterojunctions of composition and morphology that can be selected independently. We fabricated photovoltaic (PV) devices with extremely high densities (10^14/mm^2) of interpenetrating nanoscale columnar features in the active polymer blend layer. The smallest feature sizes are as small as 25 nm, which results in a spacing of heterojunctions at or below the exciton diffusion length. Photovoltaic devices based on double-imprinted poly((9,9-dioctylfluorene)-2,7-diyl-alt-[4,7-bis(3-hexylthien-5-yl)-2,1,3-benzothiadiazole]-2,2′,2″,2‴-diyl] (F8BTBT)/poly(3-hexylthiophene) (P3HT) films are among the best polymer–polymer blend devices reported to date with a power conversion efficiency (PCE, η) of 1.9%.

KEYWORDS Polymer photovoltaics, nanoscale morphology, nanoimprint lithography, polymer blends

Since the first reports on polymer bulk heterojunction (BHJ) devices, the importance of an interpenetrating, nanoscale network morphology of phase-separated donor and acceptor materials has been recognized.1,2 Such structures provide the spatially distributed interfaces necessary for efficient charge separation of the photogenerated excitons and direct pathways for collecting electron and holes. Current device fabrication is based on spincoating and annealing procedures, which result in highly irregular, irreproducible morphologies that strongly depend on processing conditions and materials used.3–7 The efficiency of the phase-separated interpenetrating donor–acceptor results from the ability to efficiently dissociate photogenerated excitons and transport the dissociated charges to the respective electrodes. Since the first reports on polymer blend devices, device efficiencies have increased considerably through improvements in materials, processing, and control over the morphology. Sustained efforts have improved polymer PV devices based on fullerene derivatives in combination with electron-donating polymers such thiophene polymers to efficiencies η_e in the range of 4–7%.8–11 All-polymeric devices would overcome the low extinction coefficient and reduced open-circuit voltage associated with fullerenes and allow the use of a much wider range of materials. Although much less research has been devoted to all-polymer PV devices, promising improvements in efficiency to around 1.8% have been reported12–14 with a very recent report on blends of poly(phenylthiophene) and poly-[(cyanovinylene)phenylene] derivatives even reaching 2.0%.15 To further improve the efficiency of all-polymeric BHJ devices, the internal interfacial area must be as large as possible, while continuous pathways for the dissociated charges to reach the electrodes must be maintained. For spin-coated polymer blends, this means that phase separation needs to be arrested at the nanometer scale as the exciton diffusion length is in the order of 10 nm and micrometer phase separation significantly diminishes device performance.3,7 Even when this is achieved, the randomly interspersed electron donor and acceptor phases can lead to charge trapping,16 or incomplete photoluminescence (PL) quenching in the regions of conjugated polymer that are more than an exciton diffusion length away from an acceptor.17 Spin-coating procedures involving highly volatile solvents have been developed to optimize the phase separation process.18–20 However, the morphologies formed in spin-coated films are very strongly dependent on processing conditions (spin speed, solvent, temperature, humidity, concentration) as well as the materials used. The lack of control in device fabrication greatly hampers the systematic study of the properties of demixed blend PV devices and restricts their exploitation in large-area solar cells.

Here, we present a completely new approach to nanopatterned polymer blends through nanoimprint lithography (NIL),21 as shown schematically in Figure 1. A detailed description of the imprinting method, as well as details on
the materials used, is given in the Supporting Information.

First, a spin-coated film of the electron donor polymer P3HT on PEDOT/PSS-coated ITO/glass or poly(ethylene terephthalate) (PET) substrate was patterned in a first nanoimprinting step. As P3HT is easily oxidized and degrades at elevated temperatures (above 60 °C), we employed solvent-vapor-assisted nanoimprint lithography (SANIL) under N2 flow and imprinted at room temperature and low pressure (for full experimental details see Supporting Information). Prior to demolding and the subsequent imprinting of F8TBT films, the patterned P3HT films were thermally annealed to improve the crystallinity and mechanical strength. The crucial part of our procedure is to use the first patterned film as a stamp in the second imprinting step of the acceptor polymer F8TBT, which was spin-coated on a thermally evaporated Al cathode on a Si wafer or Kapton substrate, resulting in a double-imprinted PV device. Hence, upon double imprinting a functional photovoltaic device based on a bilayer polymer blend film with precisely defined interface geometry was formed. This approach leads to precisely defined, interdigitated polymer bilayers with structures at the 25 nm level. Furthermore, the anode is completely covered with the electron donor material and likewise the cathode is covered with the electron acceptor polymer. There is therefore a direct pathway for all charges generated.

It should be noted that our method is rather different from initial reports in the literature on PV devices containing imprinted P3HT. These studies used relatively large imprinted features and electron accepting small molecules (PCBM, perylene) that were deposited either on the initial film after cross-linking, or via vapor deposition. Our method, which is based on a manufacturable and scalable technology, is suitable for any polymer combination with a difference in $\Delta T_g$, regardless of interaction parameter $\chi$, solubility properties, and molecular weights.

To perform a systematic study of the influence of feature size and interface area on PV device performance, a series of masters were either obtained commercially from NIL Technology ApS or fabricated in-house using e-beam lithog-
raphy. The molds contain 75–80 nm deep 2D dot patterns with feature sizes of 200, 150, 100, 80, 40, and 25 nm and equivalent spacing (i.e., pitch is double the feature size). The total imprinted P3HT/F8TBT area was $4 \times 2 \text{ mm}^2$ for all patterns, forming 6 pixels of PV devices in each double imprinting experiment.

To investigate the internal structure of the P3HT/F8TBT interface, the two layers were either physically prised apart or the F8TBT layer was dissolved in a selective solvent (CH$_2$Cl$_2$) to reveal the imprinted P3HT surfaces for SEM and AFM measurements (Figure 2). In general, all features over 80 nm are nearly perfectly replicated over the whole area of the stamp. The high (>$3:1$) aspect ratio of the 25 nm dots leads to some distortion in the P3HT pillars and the F8TBT holes are not uniform. Furthermore, Figure 2c,d shows that the features in P3HT and F8TBT are exact replicas of each other, confirming that the imprinted polymer film acts as a robust stamp in the second imprinting step.

Devices. Previous studies have shown that only annealed blends of P3HT and F8TBT produced efficient photovoltaic devices.$^{11}$ A detailed study using optical absorption and photoluminescence spectroscopy revealed that the device
efficiency could be attributed to an increase in the dissociation efficiency of bound electron–hole pairs resulting from improved carrier mobilities in ordered materials. During the fabrication of the double-imprinted PV cells, the P3HT film was exposed to chloroform (CHCl₃) and dichloromethane (CH₂Cl₂) while both the P3HT and F8TBT films underwent thermal annealing during the second imprinting step, followed by a post imprinting annealing step (120 °C for 5 min). As seen in Figure 3a, a characteristic shoulder centered at ~610 nm was observed in the UV–vis absorption spectra of P3HT, the intensity of which is correlated with the degree of crystallinity of P3HT. The shoulder increases significantly upon thermal annealing, but is already present directly after SANIL and this might be attributed to the effect of nanoconfinement in the imprinting mold, which can enforce order in rigid, (liquid) crystalline polymers.²⁸,²⁹

PL measurements (Figure 3b) showed strong quenching in imprinted P3HT/F8TBT films and a decrease of PL intensity as pattern feature size decreased. The imprinting process itself led to only a small (10%) reduction in the PL intensity of the F8TBT film after double-imprinting and subsequent removal of the P3HT layer. Very strong PL quenching (by 87% in comparison to imprinted F8TBT at 651 nm) was observed in the double imprinted films with 25 nm features, strongly indicating that these dimensions are similar to or smaller than the exciton diffusion length in both materials. Indeed, the residual emission appears to be coming from P3HT, suggesting that the F8TBT emission is almost completely quenched. Interestingly, the PL intensities

<table>
<thead>
<tr>
<th>Feature size-width (nm)</th>
<th>( A/A_{0} )</th>
<th>( A_{0} )</th>
<th>( V_{oc} ) (V)</th>
<th>( J_{sc} ) (mA/cm²)</th>
<th>( FF )</th>
<th>( PCE ) (%)</th>
</tr>
</thead>
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<tr>
<td>planar</td>
<td>1</td>
<td>1.06</td>
<td>0.94</td>
<td>0.36</td>
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<tr>
<td>patterned</td>
<td>200</td>
<td>1.45</td>
<td>0.08</td>
<td>0.88</td>
<td>0.77</td>
<td></td>
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<tr>
<td>2D dot array (width=space)</td>
<td>150</td>
<td>1.60</td>
<td>1.12</td>
<td>1.99</td>
<td>0.39</td>
<td></td>
</tr>
<tr>
<td></td>
<td>100</td>
<td>1.90</td>
<td>0.96</td>
<td>0.43</td>
<td>0.97</td>
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<tr>
<td></td>
<td>80</td>
<td>2.00</td>
<td>1.14</td>
<td>2.35</td>
<td>0.43</td>
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</tr>
<tr>
<td></td>
<td>40</td>
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<td>2.79</td>
<td>0.47</td>
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</tr>
<tr>
<td></td>
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<td>4.20</td>
<td>1.14</td>
<td>3.30</td>
<td>0.49</td>
<td>1.85</td>
</tr>
<tr>
<td>blend</td>
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<td>1.12</td>
<td>2.32</td>
<td>0.42</td>
<td>1.09</td>
</tr>
</tbody>
</table>

\( A/A_{0} \) is donor/acceptor interface area ratio of patterned to planar-interface PV devices. \( I_{0} \) illumination intensity equivalent to 100 mW cm⁻² after spectral mismatch correction using AM 1.5G solar simulator.

PL measurements (Figure 3b) showed strong quenching in imprinted P3HT/F8TBT films and a decrease of PL intensity as pattern feature size decreased. The imprinting process itself led to only a small (10%) reduction in the PL intensity of the F8TBT film after double-imprinting and subsequent removal of the P3HT layer. Very strong PL quenching (by 87% in comparison to imprinted F8TBT at 651 nm) was observed in the double imprinted films with 25 nm features, strongly indicating that these dimensions are similar to or smaller than the exciton diffusion length in both materials. Indeed, the residual emission appears to be coming from P3HT, suggesting that the F8TBT emission is almost completely quenched. Interestingly, the PL intensities
of the double imprinted films containing 100 and 80 nm features were also strongly affected (only 67 and 62% PL remaining at 651 nm, respectively). These results are consistent with an F8TBT exciton diffusion range of 10 nm. By changing the imprint pattern, double imprinting has the potential to allow the dimensions of both phases to be independently tailored to match the respective exciton diffusion length in either phase. This is a key advantage of the technique and it might help in identifying new acceptor materials that are not based on fullerenes.

Table 1 presents a concise summary of the main performance parameters of nanostructured solar cells. All imprinted cells exhibited a high open circuit voltage ($V_{OC}$) > 1.1 V, comparable to the blend control device fabricated under the same conditions as previously reported.24

Figure 4 shows the significant increase of the external quantum efficiency (EQE) with decrease in feature sizes with the spincoated polymer blend performing roughly equal to the 80 and 100 nm imprinted films. The current density–voltage ($J–V$) characteristics show significant increases in both short circuit current density ($J_{SC}$) with decreasing feature sizes. The $J–V$ curve of the blend control device overlaps with that of the 40 nm featured imprinted one, although the latter shows an improved fill factor (FF).

A clear improvement in the PCE of the nanostructured devices is observed with the 25 nm features leading to a PCE of 1.85%, which is 50% higher than the blend control device. It should be noted that the first reported P3HT/F8TBT blends quoted efficiencies of 1.8% that might be attributed to a higher grade F8TBT, a more reproducible value for the efficiency of blend devices is around 1%.11,25 The most notable influence of nanopatterning on device performance can be seen in the fill-factor, which increases to the highest reported value for all-polymer devices (0.49) for the 25 nm features. Previous work on modeling of the behavior of nanostructured organic photovoltaic devices,30 identified a number of possible reasons for an improved FF. We suggest that improved hole charge carrier mobility and better geminate pair dissociation in patterned devices contribute to the improved FF. In a blend device, geminate pair separation might be impeded by the intermixed morphology, whereas in the imprinted structures (as in bilayer devices) geminate pairs have more direct pathways to charge separation. Further experiments will be required to verify the origin of the high fill factors observed in the imprinted devices. Furthermore, the double imprinting process ensures that both the donor and acceptor polymer are completely pure, whereas spincoated blends not always fully phase-separate, leading to suboptimal charge mobilities. Finally, we note that in spincoated devices, it is usually impossible to avoid wetting of the “wrong” polymer at either electrode, whereas our devices have pure polymer layers adjacent to the appropriate electrodes, preventing diffusion of carriers to the wrong electrode.

Conclusion. In summary, we have shown that this novel imprinting method produces the best performance yet reported for a polymer–polymer system and this improvement results primarily through the improved fill factor over that obtained for solution demixed devices. We consider that this is due to the avoidance of locally trapped photogenerated charges due to the poorly controlled morphology formed from the demixed polymer blend. The absolute efficiency of our devices is limited by the 80 nm height of the imprinted structure as shown in Figure 2a. Current devices only absorb 58% of the available solar intensities between 375 and 640 nm (based on optical modeling of the device structure). Hence there is considerable room for improvement in power conversion efficiency if the device thickness can be increased while retaining efficient charge separation and collection. Our work indicates that charge separation at polymer–polymer heterojunctions can be similarly effective to polymer–fullerene systems, and demonstrates that there is scope to find a broader range of electron acceptors beyond the widely used fullerenes that can provide high PV efficiency when the heterojunction morphology is controlled appropriately.

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Supporting Information Available. Materials, device fabrication, and device testing. This material is available free of charge via the Internet at http://pubs.acs.org.

REFERENCES AND NOTES


